RAPID TURNAROUND XAS PROPOSAL FORM

Application is good for one year from date of submission and is subject to staff review and approval. A **one-page description** of the planned work must be attached to this form and sent to Cathy Knotts, SSRL, 2575 Sand Hill Rd., MS 99, Menlo Park, CA 94025, or via e-mail to knotts@ssrl.slac.stanford.edu

For User Admin Use Only						
Proposal No.						
Date Received						
Experienced New						

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SPOKESPERSO	N and COLLABORATO	ORS: (list spokesperson	first)			-
Full Name	Full Institution Addre			Fax Number	E-mail	<u>Degree</u>
(First, MI, Last)						
PROPOSAL TIT	LE:					
	RIBE THE PROBLEM	TO RE STUDIED. (P	lease limit	to 300 words/	2000 characte	arc).
DRIEFLI DESC	RIDE THE I ROBLEM !	TO BE STODIED. (F)	iease iiiiiit	io 300 words/.	2000 Characte	15).
SCHEDULING I	NFORMATION:					
Samples:		Sample Concentration	n:	I	Energies/Edge	es:
Crystal: Si(111) _	Si(220)	Orientation: phi=0	phi=90) no pre	ference	
	ded?: YES() NO()	•	•	_		
Have you had prev	vious experience at a synch	nrotron facility? YE	s 🗆 no	If yes, where	e and when?	
•	vious experience at SSRL?	•		•		
• 1	sly carried out XAS experi					of experience on attached sheet.
Number of 8-hour	shifts requested: (N	Maximum for new user	is 12 shifts	; experienced	user is 18 shi	fts)
POTENTIAL SA	FETY CONCERNS OR	HAZARDS:				
Please complete s	afety questions below. Ac	dditionally, provide d	etailed safe	ety procedure	s in proposa	ıl text.
CHEMICAL USI	F2()NO()Vas					
Common Name:_						
NANOSCALE M	ATERIALS USE? ()No	()Yes				
- If yes, will th	here be open manipulation	of nanoscale material s	samples at	SSRL?()No	()Yes	
	re the samples contained? _ ety plan must be submitted		·C: C	1 C C	DC/MIOCH	
	cty plan must be submitted lc.gov/niosh/topics/nanoted		nce for app	orovar. See Ci	JC/NIOSH V	redshe for guidance.
•						
	JS MATERIALS USE? (type & what		assification	1		
11 Jes, what	What	are materials 11111 Cl		*		
	OM HUMAN OR ANIM	* * *	. ,	further anidor	Ce	

*Ra		als specific activity not be brought directly to SSR	L. They first must be shipped or ta A 94025, or contact Ray Russ at 6		
LAS	SER USE? ()No ()Yes				
	- If yes, ANSI classification Laser hazards controls you	n:Wavelength: will apply:	Total power:		
HAZ	ZARDOUS EQUIPMENT	VELECTRICAL EQUIPMENT	Γ? ()No ()Yes		
	- If yes, describe hazardous and if it has been altered in		bringing to SSRL. Indicate if it is a	commercial product, certified,	
at fu	ll cost recovery.) Will priv	RCH: (Private sector research is ate sector research be performed REPORTING PURPOSES:	subject to specific terms and condition under this application? \square YE		
KE	ZOIRED FOR DOE//VIII		(check all that apply)		
	Materials Science	Polymers	Earth Sciences	Engineering	
	Physics	Medical Applications	Environmental Sciences	Instrumentation or Other Development	
	Chemistry	Biological and Life Sciences	Optics	Purchase of Specialty Services or Materials	
	Other: (specify)				
			Y (check all that apply)		
	DOE/BES	DVA	NSF	Fdn/Research Inst.	
	DOE/BER	NASA	USDA	State/County/City	
	DOE Other: (specify) NIH Other US Gov't: (specify)		Other US Gov't: (specify)	Prof/Voluntary Assoc.	
	DoD: (specify)	NIST	Industry	Foreign: (specify)	
	Other: (specify)				
IF Y SSR list l	YOU HAVE PREVIOUSL L RELATED PUBLICAT below or append to this pr	TIONS, PATENTS AND/OR A	AT SSRL, HAVE YOU NOTIFIED WARDS?	NO If not previously reported	
	OU PUBLISHED RESUINDING SOURCES IN TH		RL BEAM TIME, DID YOU ACK ☐ YES	NOWLEDGE SSRL AND ☐ NO (If not already	

done, please refer to instructions and sample acknowledgements at www-ssrl.slac.stanford.edu/pubs)